

# Optical Link ASICs for LHC Upgrade

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# Outline



- Introduction
- VCSEL driver chip
- PIN receiver/decoder chip
- Clock multiplier
- Summary



### Introduction



- 1st phase of LHC upgrade is planned for 2013:
  - ◆ 3 times increase in luminosity to 3x10<sup>34</sup> cm<sup>-2</sup>s<sup>-1</sup>
  - expect significant degradation in the ATLAS pixel detector
  - ⇒ add an insertable barrel layer (IBL) at radius of 3.7 cm
- Possible upgrade for on-detector optical readout system for the IBL:
  - add new functionalities to correct for deficiencies in current system
  - upgrade current optical chips to run at higher speed
  - some of the development could be of interest to SLHC upgrade
  - use 130 nm CMOS 8RF process
  - prototype chips received/irradiated in July/August 2008
  - results will be presented below



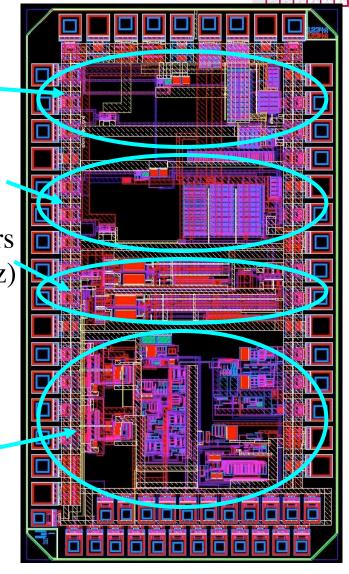
Opto-Chips



3.2 Gb/s VCSEL driver

640 MHz clock multipliers (4 x 160 and 16 x 40 MHz)

PIN receiver/decoder (40, 160, 320 Mb/s)



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TIPP09

2.6 mm x 1.5 mm



- chips were tested in the lab at Ohio State University
- chips were irradiated with 24 GeV protons to SLHC dose at CERN
  - 8 VCSEL drivers: 4 "slow" + 4 "fast"
  - 4 PIN receiver/decoder (purely electrical testing)
  - 4 PIN receiver/decoder coupled to PIN
  - 4 clock multiplier
  - long cables limited testing of driver/receiver to 40 Mb/s
  - special designed card allows testing of clock multiplier at 640 MHz

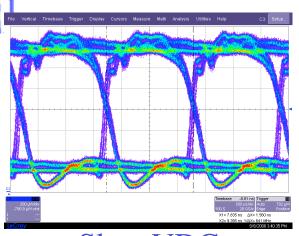


protons

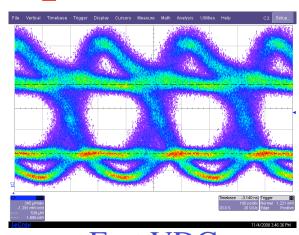


# VCSEL Driver Chip





1 35 All Prints
1 35 All Print



Slow VDC 640 Mb/s ~ 14 mA max

Fast VDC 640 Mb/s ~ 9 mA max

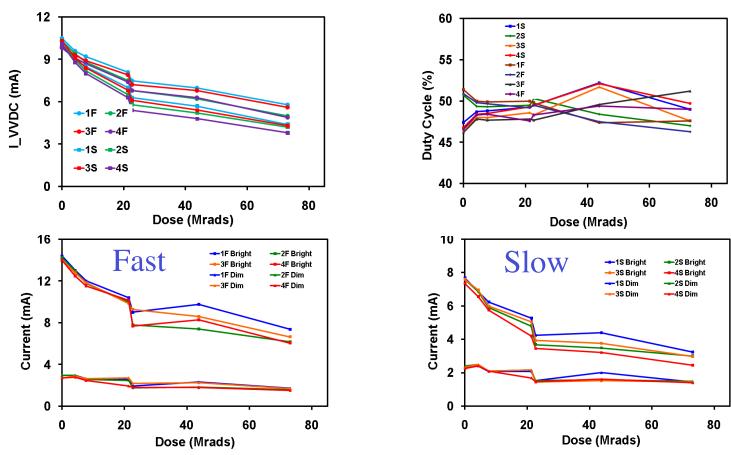
Fast VDC 3.2 Gb/s

- both slow/fast chips are working
- LVDS receiver/VCSEL driver work at high speed
  - ◆ BER < 10<sup>-13</sup> @ 4 Gb/s using 10 Gb/s AOC VCSEL



## **VDC** Irradiation





- VDC driving 25  $\Omega$  with constant control current (Iset)
- drive current decreases with radiation for constant Iset
  - driver circuit fabricated with thick oxide process



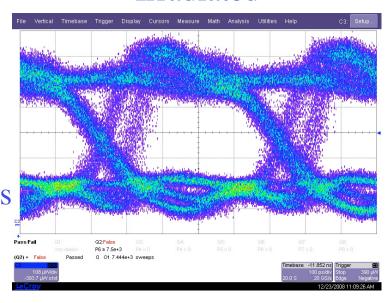
# Unirradiated vs. Irradiated VDC



#### Unirradiated

# 

#### **Irradiated**



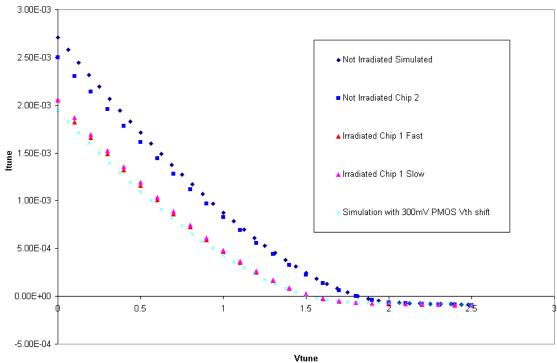
- VDC driving 2.5 Gb/s Optowell VCSEL
- Possible to obtain similar eye diagram by adjusting control currents
  - radiation induced changes in control current circuitry



# Threshold Shift in Irradiated PMOS



ТЗ



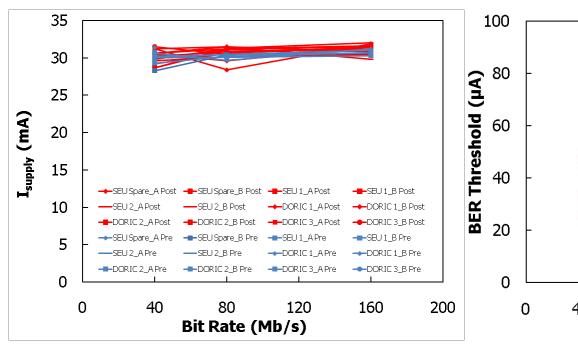
- Have access to two transistors for characterization
  - simulation with 300 mV threshold shift reproduces observed V vs. I
  - PMOS and NMOS have different threshold voltage shifts
  - ⇒ will use only PMOS in the current mirror

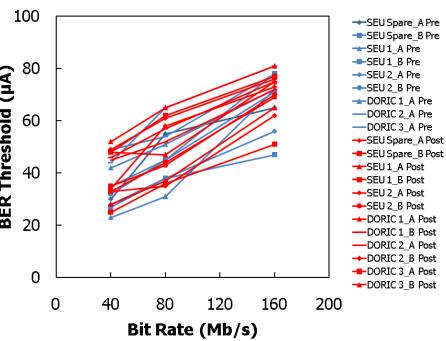


# Receiver/Decoder Chip



- Designed to operate at 40, 160, and 320 Mb/s
  - can only achieve 250 Mb/s due to lack of time before submission
  - no significant degradation up to SLHC dose



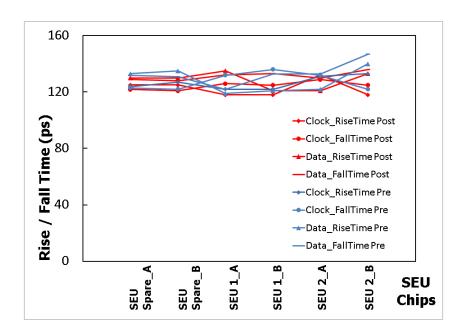


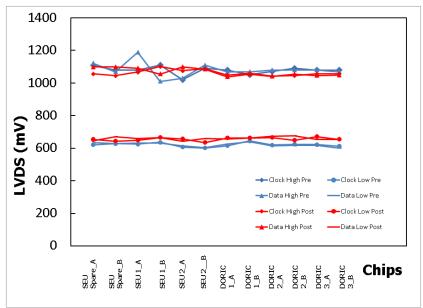


# Low Voltage Differential Driver



- output has fast rise and fall times
- output has proper amplitude and baseline
  - ◆ small clock jitter, e.g. < 50 ps (1%) @ 160 MHz
  - no significant degradation up to SLHC dose



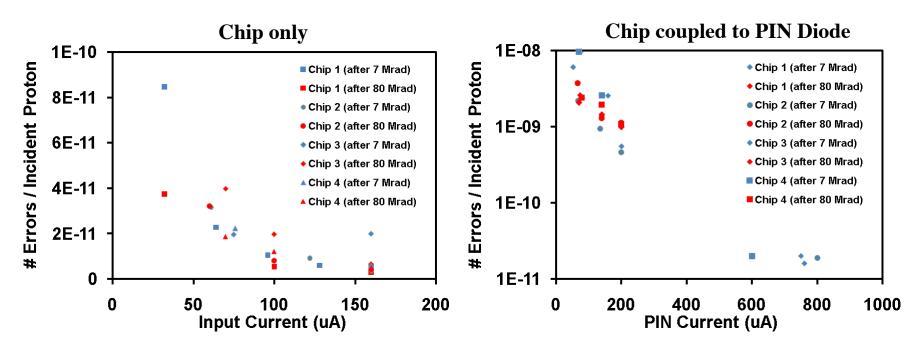








- Single event upset (SEU) measured with receiver/decoder coupled to a Taiwan PIN for 40 Mb/s operation
- SEU rate much higher for chip coupled to PIN as expected
- no significant degradation with radiation observed

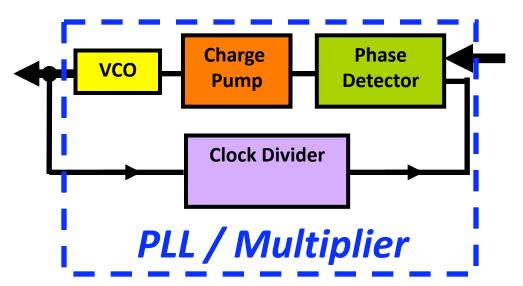


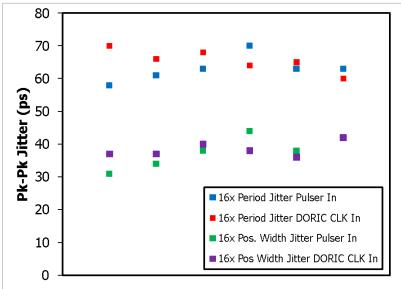


# Clock Multiplier



- clock multiplier needed to serialize high speed data
- both 4 x 160 MHz and 16 x 40 MHz clock multipliers work
  - use of recovered clock as input does not increase jitter

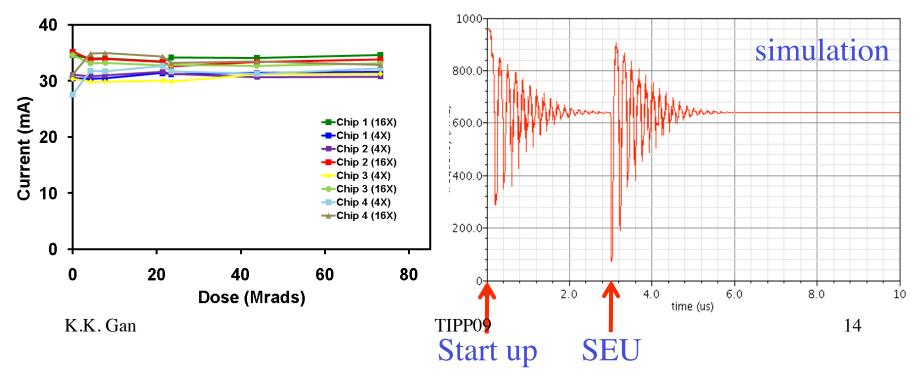




# 

# Clock Multiplier

- SEU in PIN coupled to data/clock decoder disturbed the input clock
- ⇒ observation confirmed with simulation
- output clock takes ~ 3 μs to recover
- two of the four chips lost lock during irradiation
  - □ need power cycling to resume operation at 640 MHz
- no change in current consumption (freq v("/outp"?result "tran-tran") "rising"?xName "time"?mode "auto"?threshold 0.15?histo...







# Summary

- first 130 nm submission mostly successful
- no significant degradation up to 73 Mrad
  - observe threshold shift in thick oxide transistor
- aim for next iteration in Spring 2009 with new functionalities
  - individual control of VCSEL currents
  - redundancy: ability to bypass a bad VCSEL/PIN channel